PROCEEDINGS OF SPIE

Nanophotonics, Micro/Nano Optics, and Plasmonics VIII

Zhiping Zhou Kazumi Wada Limin Tong Editors

5–11 December 2022 ONLINE, China

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Published by SPIE

Volume 12322

Proceedings of SPIE 0277-786X, V. 12322

SPIE is an international society advancing an interdisciplinary approach to the science and application of light.

Nanophotonics, Micro/Nano Optics, and Plasmonics VIII, edited by Zhiping Zhou, Kazumi Wada, Limin Tong, Proc. of SPIE Vol. 12322, 1232201 © 2022 SPIE · 0277-786X · doi: 10.1117/12.2670062

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Please use the following format to cite material from these proceedings: Author(s), "Title of Paper," in *Nanophotonics, Micro/Nano Optics, and Plasmonics VIII*, edited by Zhiping Zhou, Kazumi Wada, Limin Tong, Proc. of SPIE 12322, Seven-digit Article CID Number (DD/MM/YYYY); (DOI URL).

ISSN: 0277-786X

ISSN: 1996-756X (electronic)

ISBN: 9781510657106

ISBN: 9781510657113 (electronic)

Published by

SPIE

P.O. Box 10, Bellingham, Washington 98227-0010 USA Telephone +1 360 676 3290 (Pacific Time)

SPIE.org

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